

# Near-field Optical Diffraction Radiation Measurements at CEBAF

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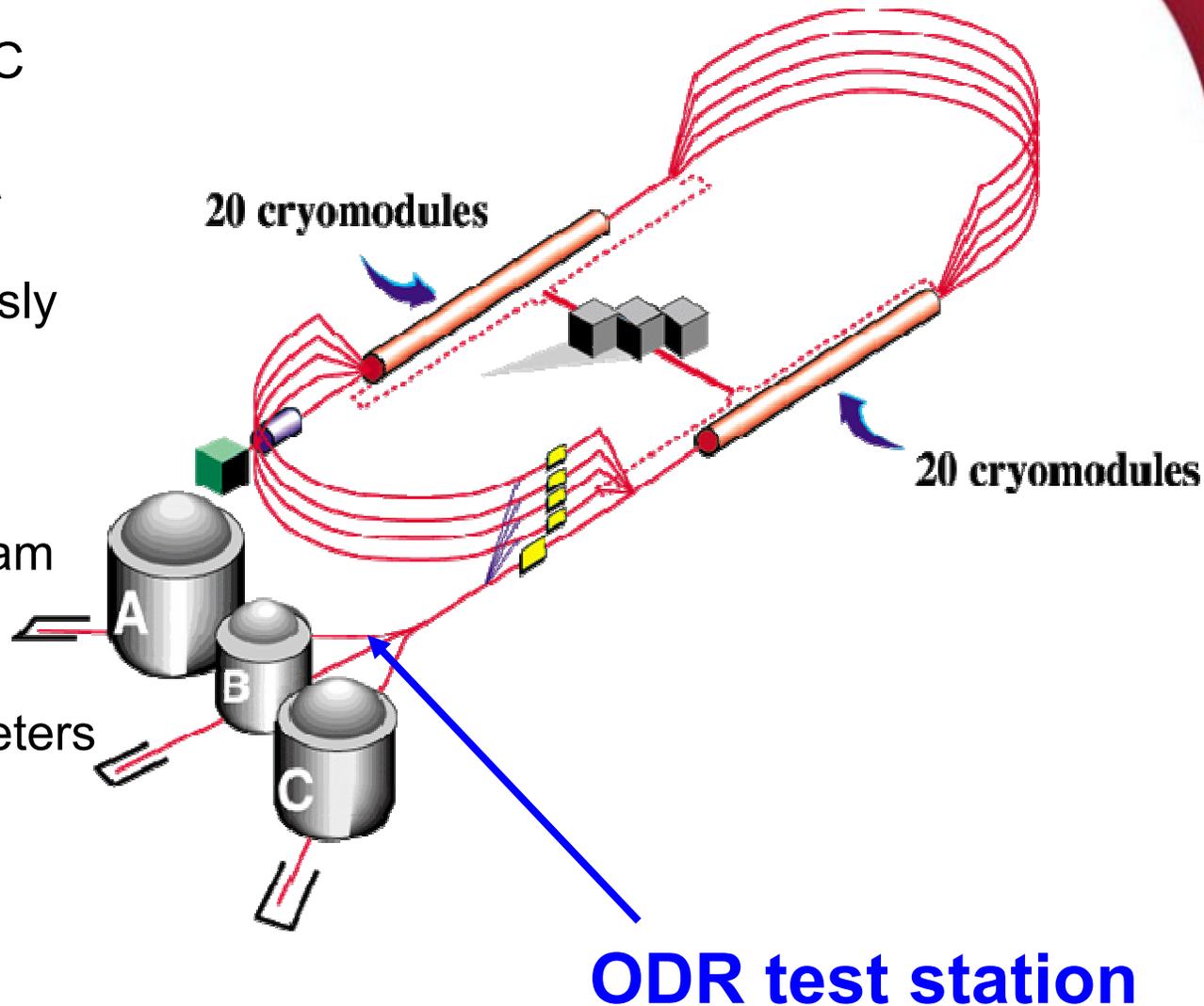
## Outline

- CEBAF brief overview
- ODR basics (why would it work?)
- experimental setup
- experimental results vs. model
- conclusion

# CEBAF

- multi-pass SRF LINAC
- up to 6 GeV – 100  $\mu\text{A}$
- 3 beams simultaneously
- $\varepsilon_g \approx 1$  nm (design)
- important to know beam size on NP targets
- monitor Twiss parameters online with CW beam

$$\frac{100 \mu\text{A}}{60\text{Hz}} = 1666.667 \text{ nC}$$



A. Lumpkin et al., FEASIBILITY OF NEAR-FIELD ODR IMAGING OF MULTI-GEV ELECTRON BEAMS AT CEBAF, PAC07

# ODR basics

amplitude of a Fourier component of transversal Coulomb field of an electron

$$E_{r\omega} = \frac{q_0 \cdot \alpha}{\pi \cdot v} K_1(\alpha \cdot r) \quad \alpha = \frac{2 \cdot \pi}{\lambda \cdot \gamma \cdot \beta}$$

$f_b(x, y)$  - transverse beam distribution

intensity of the ODR from the beam  
Is 2D convolution of the  $f_b$  and  $E_{r\omega}^2$

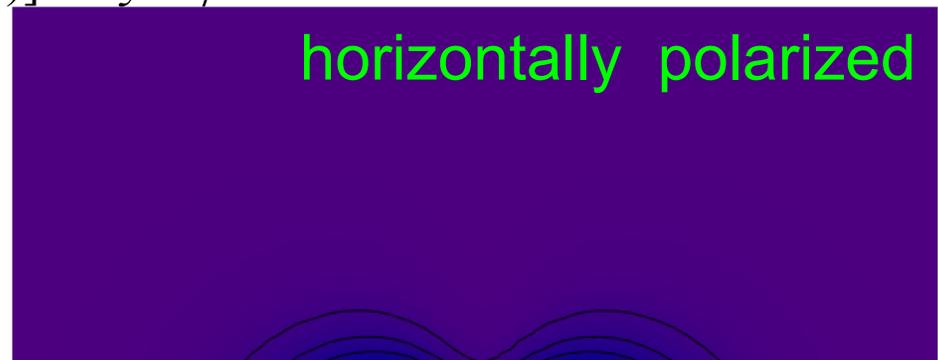
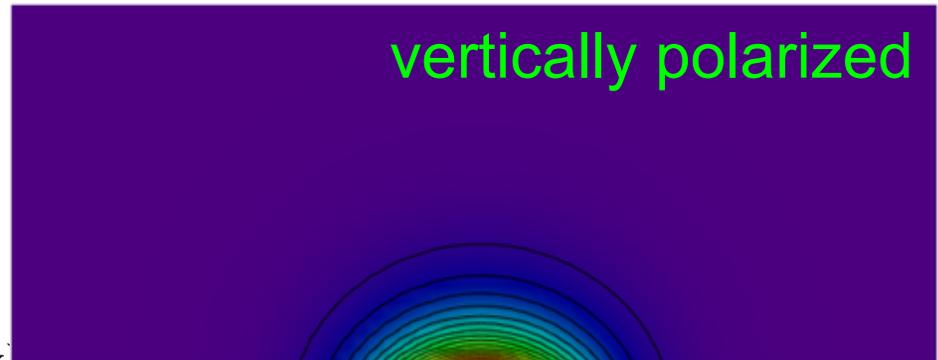
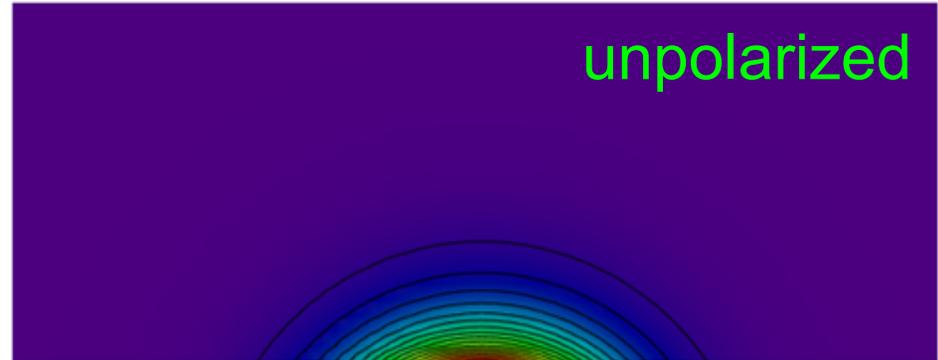
$$I_{beam} = \frac{1}{8\pi} \iint_{beam} f_b(\xi, \psi) \cdot [E_{r\omega}(\gamma, \lambda, x - \xi, y - \psi)]^2 \cdot a_\xi \cdot a_\psi$$

Example assuming

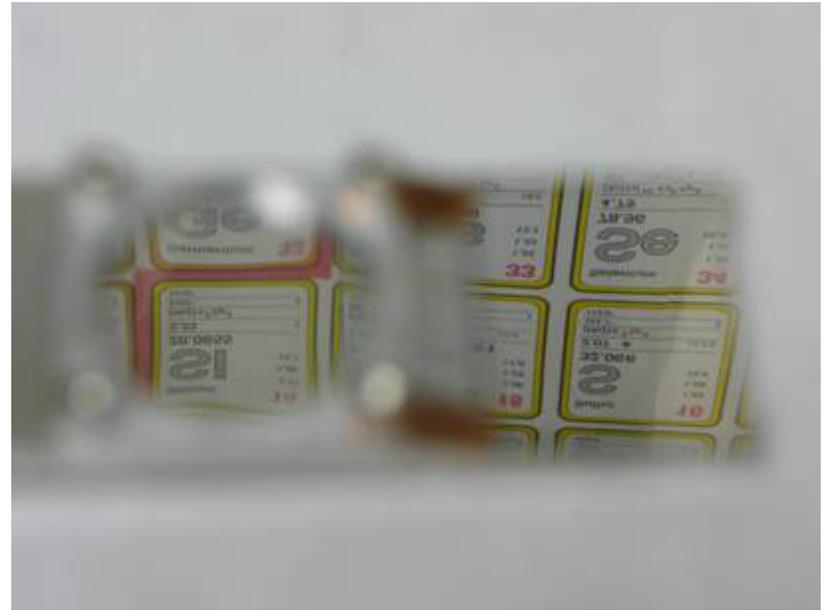
4.597 GeV;

$\sigma_x = 215 \mu\text{m}$ ;  $\sigma_y = 110 \mu\text{m}$ ;

$\lambda = 550 \text{ nm}$ ;  $h = 1.1 \text{ mm}$



# ODR-OTR radiator

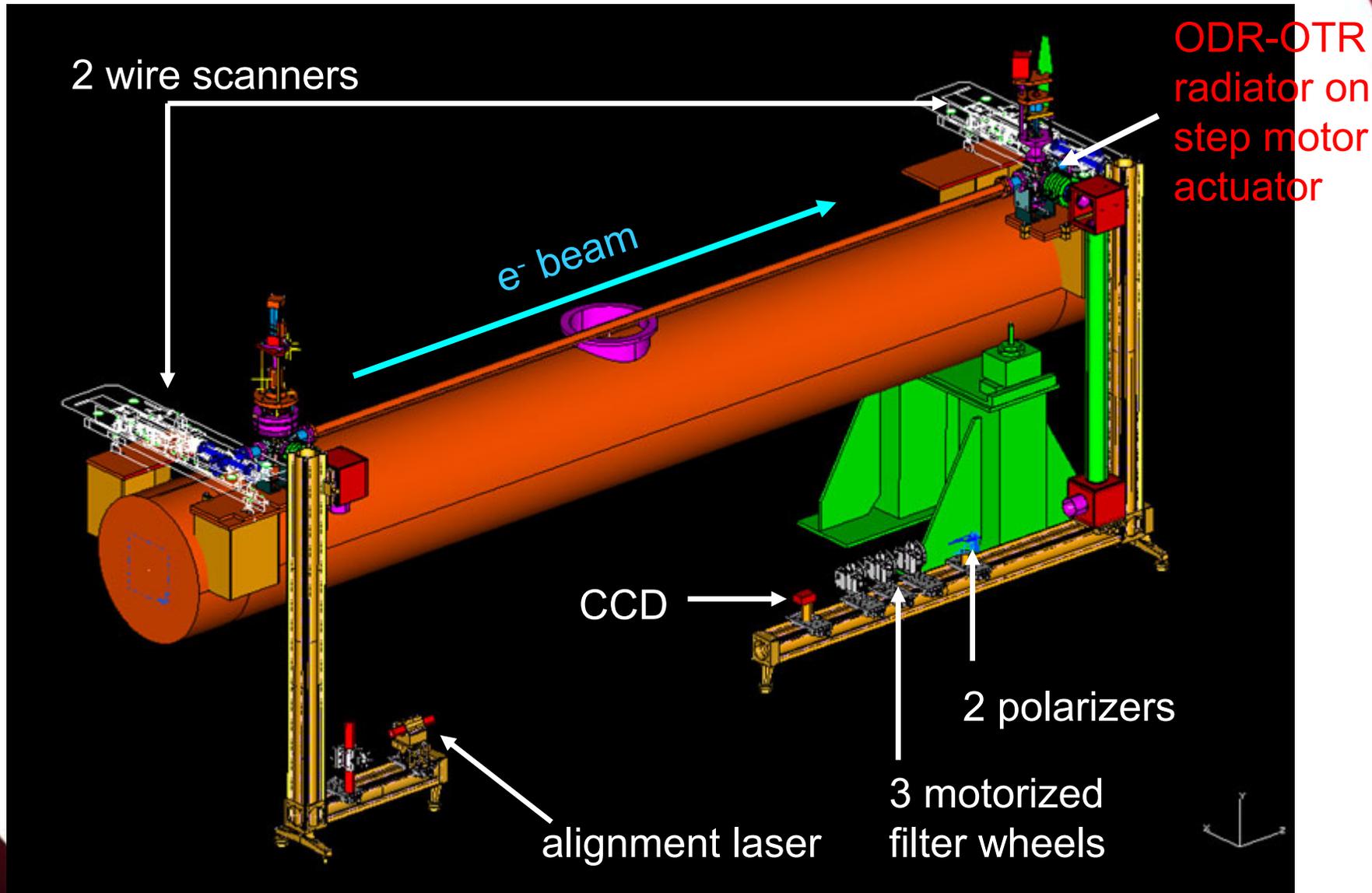


ODR radiator – 300 μm aluminized  
Si wafer 28 mm×20 mm

OTR radiator – 6 μm aluminized  
Kapton, stretched,  $\varnothing$  20 mm

both are optical quality surface  
(mirror like for optical wavelength)

# ODR setup schematic



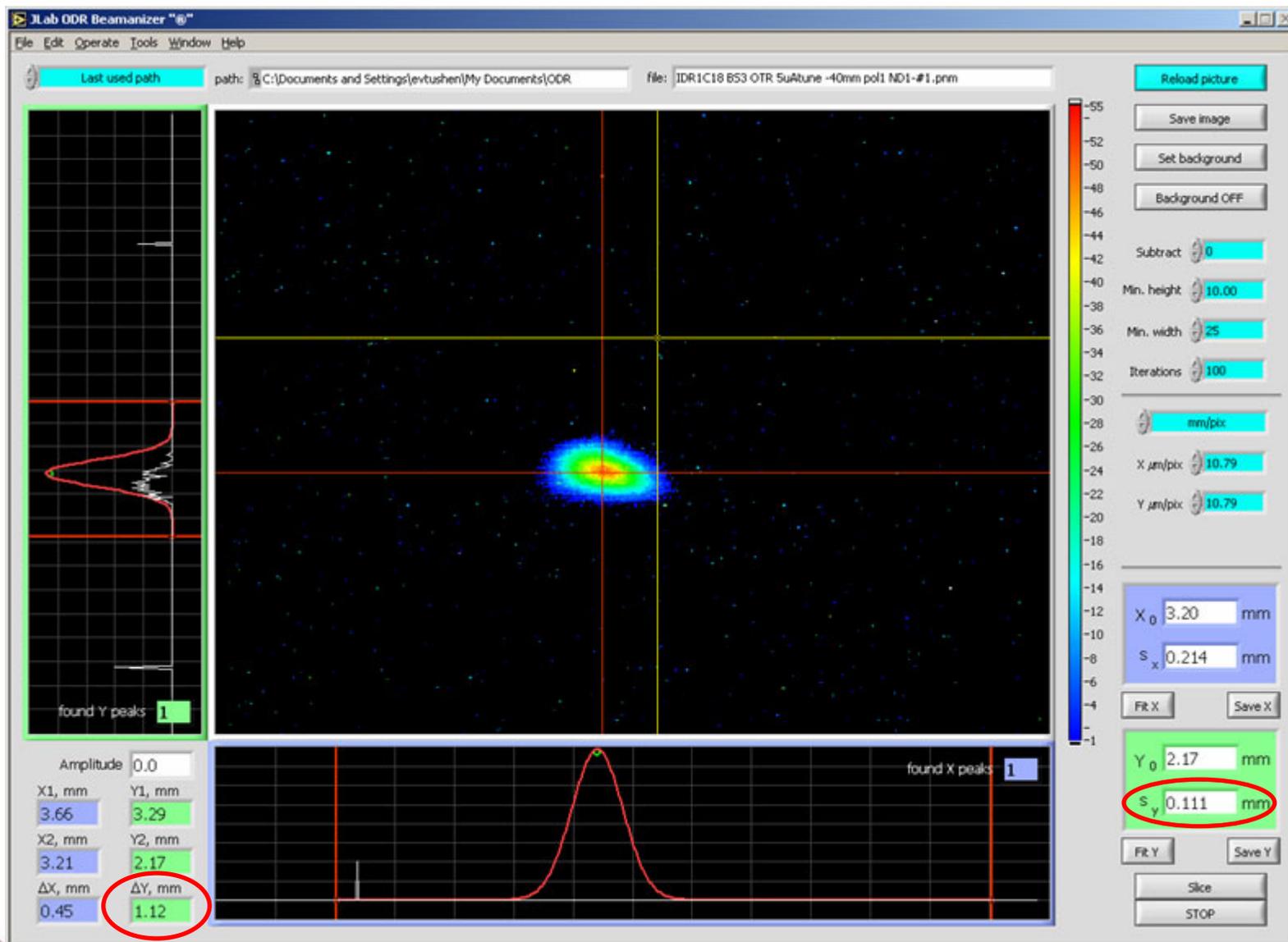
# ODR setup in tunnel



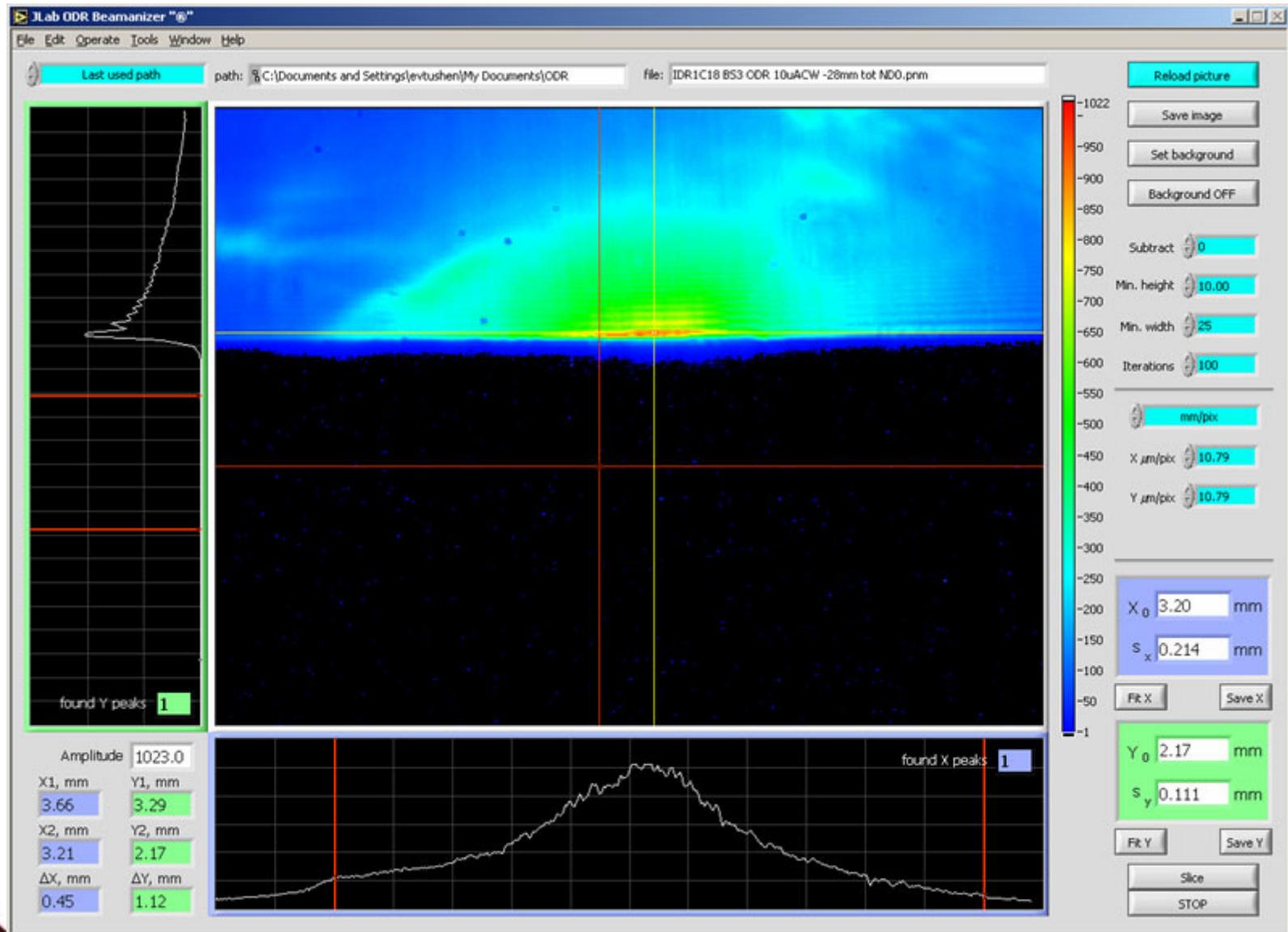
# ODR setup summary

- ODR radiator: aluminized 300  $\mu\text{m}$  Si wafer
- OTR radiator: aluminized 6  $\mu\text{m}$  stretched Kapton
  
- imaging is done with two 2'' achromatic lenses
- diffraction limit of optics is  $\sim 10 \mu\text{m}$
  
- band pass filters: 450 $\times$ 10 nm, 550 $\times$ 10nm, 650 $\times$ 10nm, 750 $\times$ 10nm, 750 $\times$ 40nm, 500nm LP, 500nm SP
- set of ND filters
- insertable polarizers (vertical and horizontal)
  
- a simple CCD camera (JAI-A60) 60 dB SNR
- frame grabber: 10-bit (National Instruments)
  
- alignment laser (set within 100  $\mu\text{rad}$  to the beam)

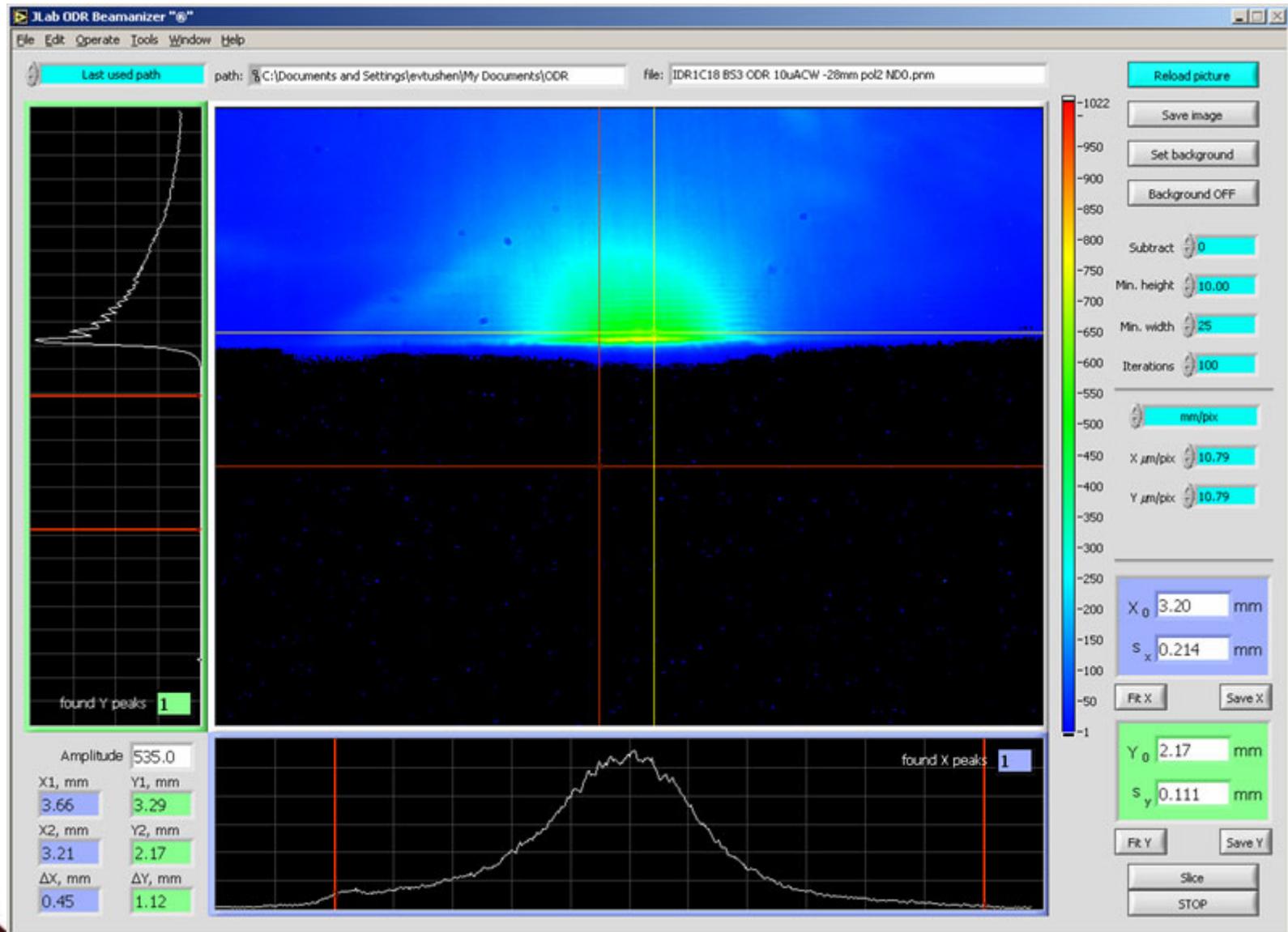
# 5 $\mu$ A tune beam; OTR



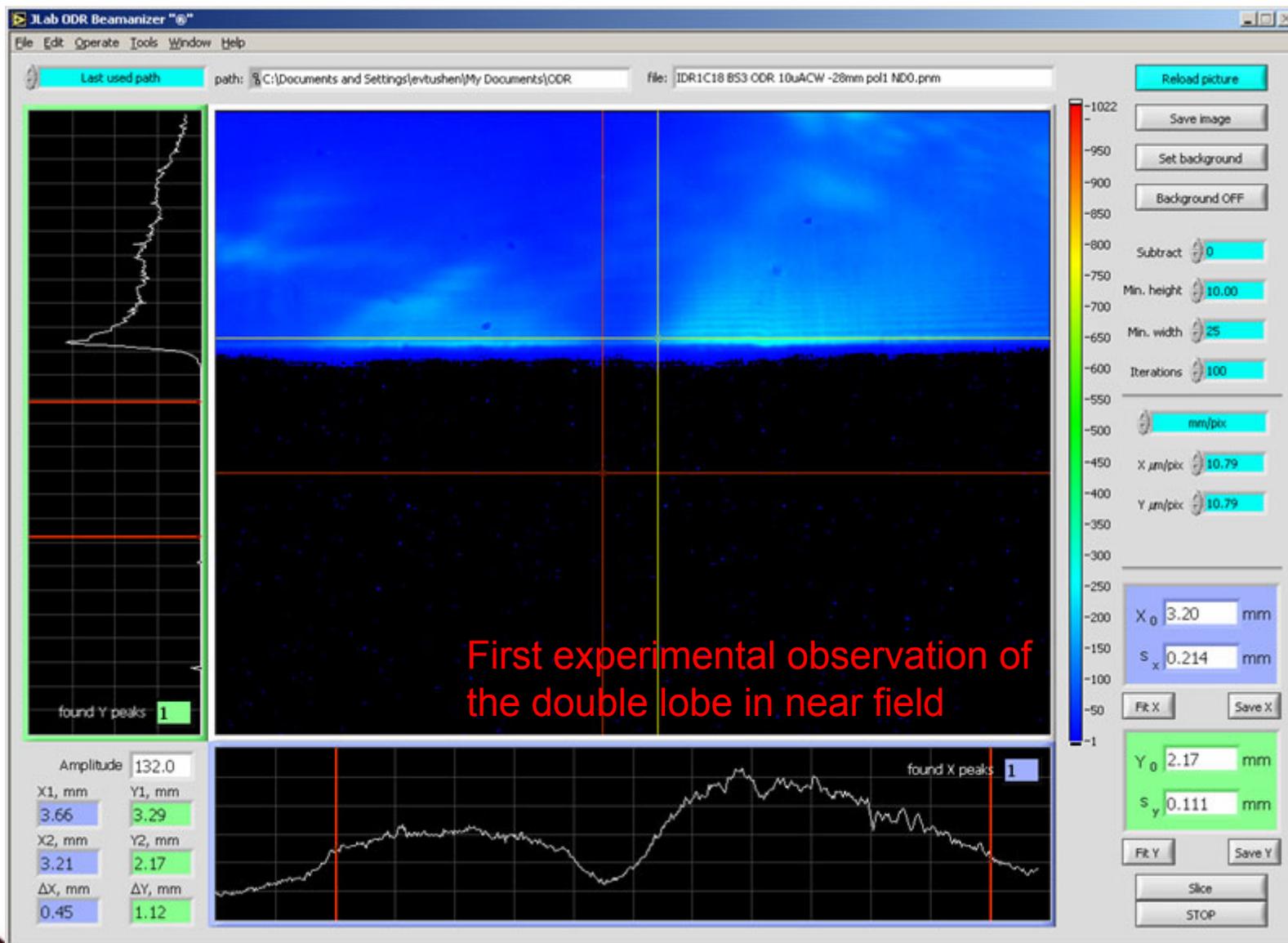
# 10 $\mu$ A CW beam; ODR unpolarized



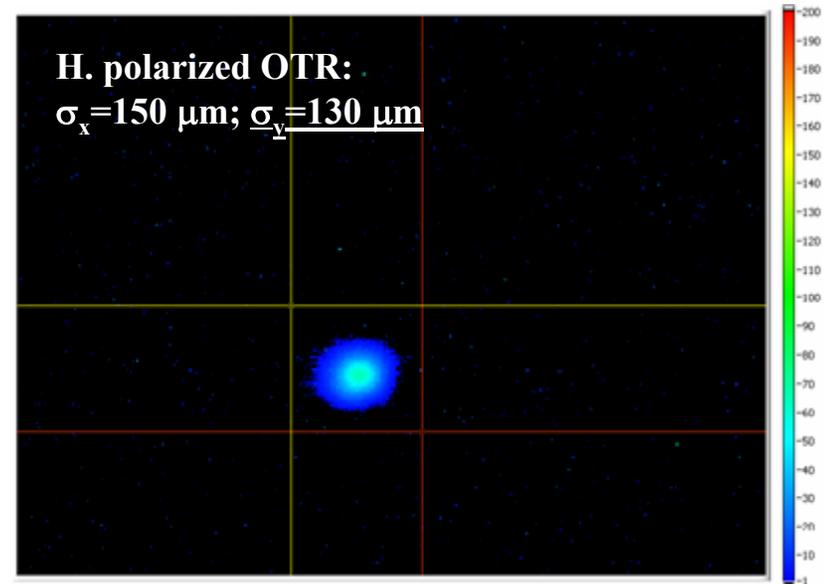
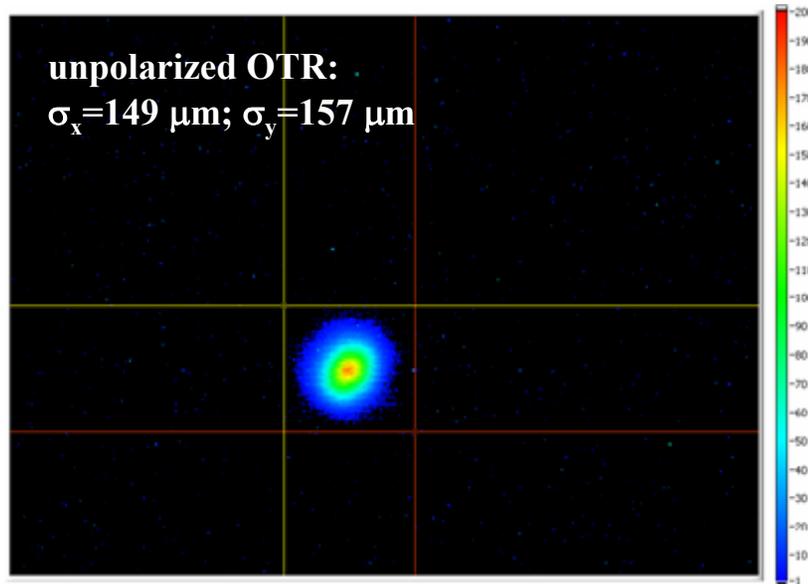
# 10 $\mu$ A CW beam; ODR V. polarized



# 10 $\mu$ A CW beam; ODR H. polarized

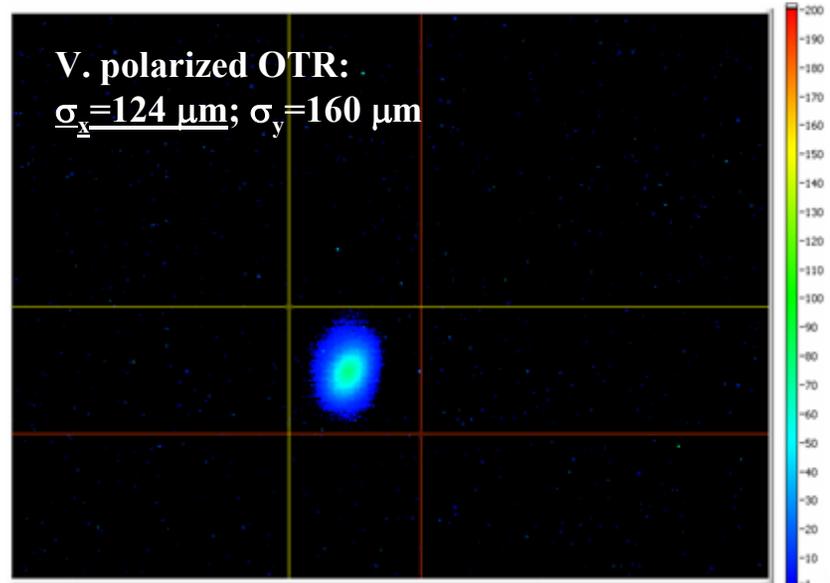


# OTR on the ODR radiator (tune beam)

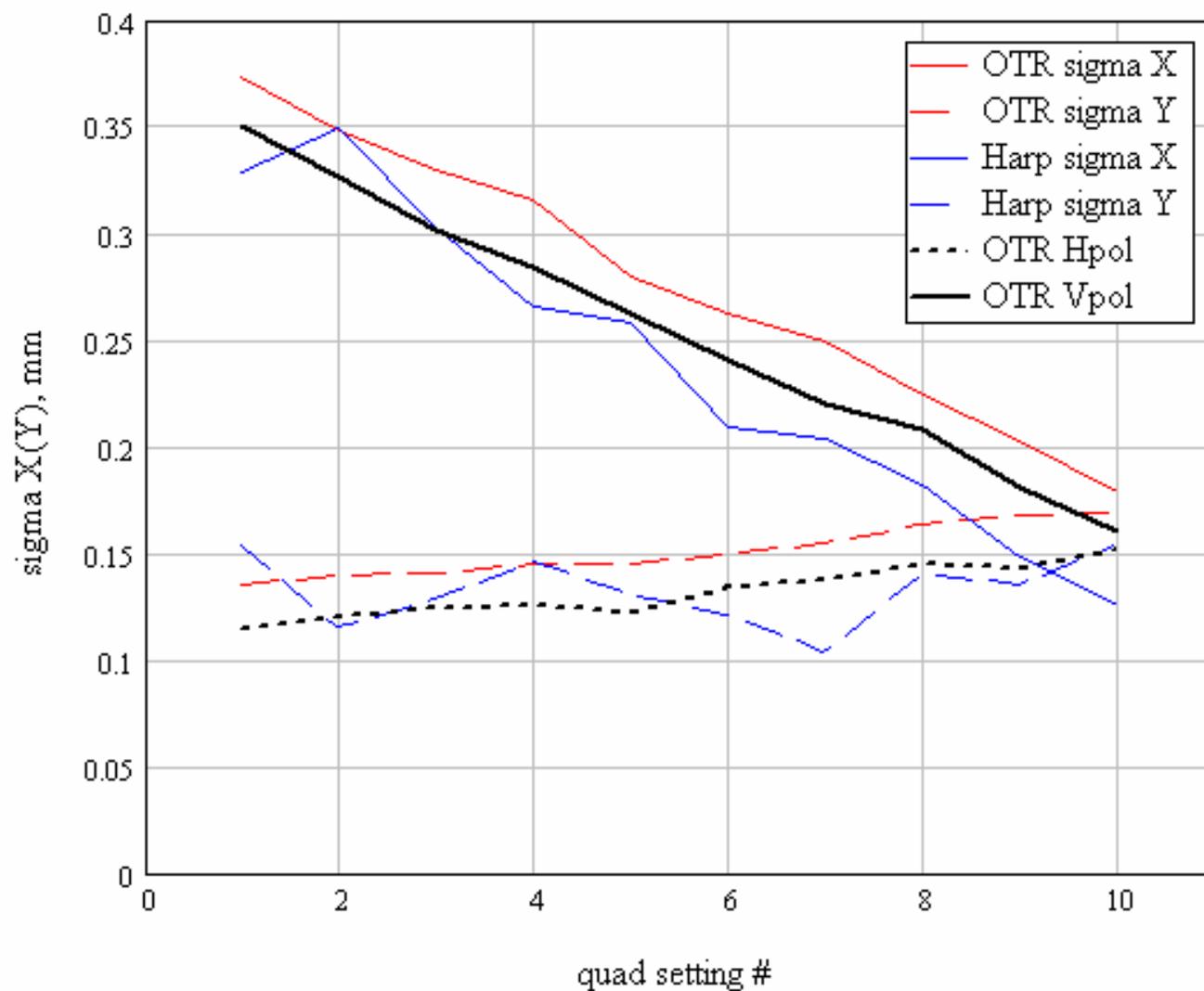


When measuring ODR pattern size vs. beam size, OTR was used to determine the actual beam size.

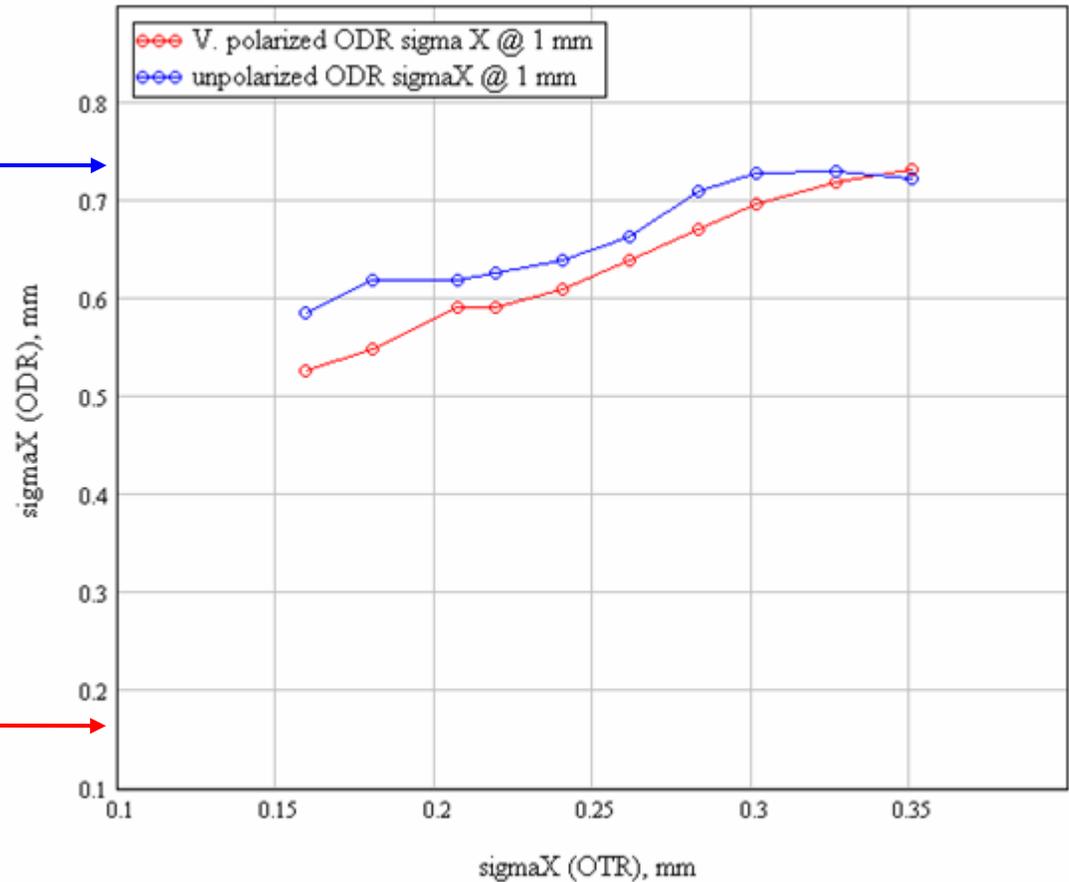
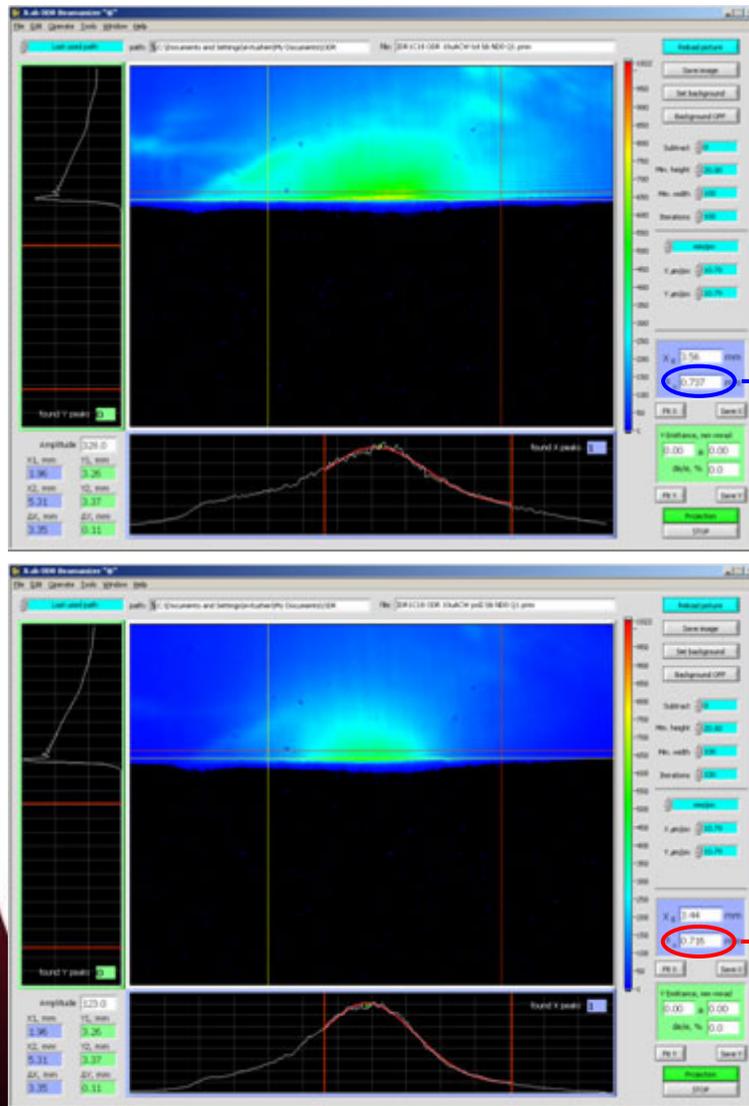
For our beam parameters ( $\sim 150 \mu\text{m}$ ) using a polarizer reduces makes 20% difference for measured beam size.



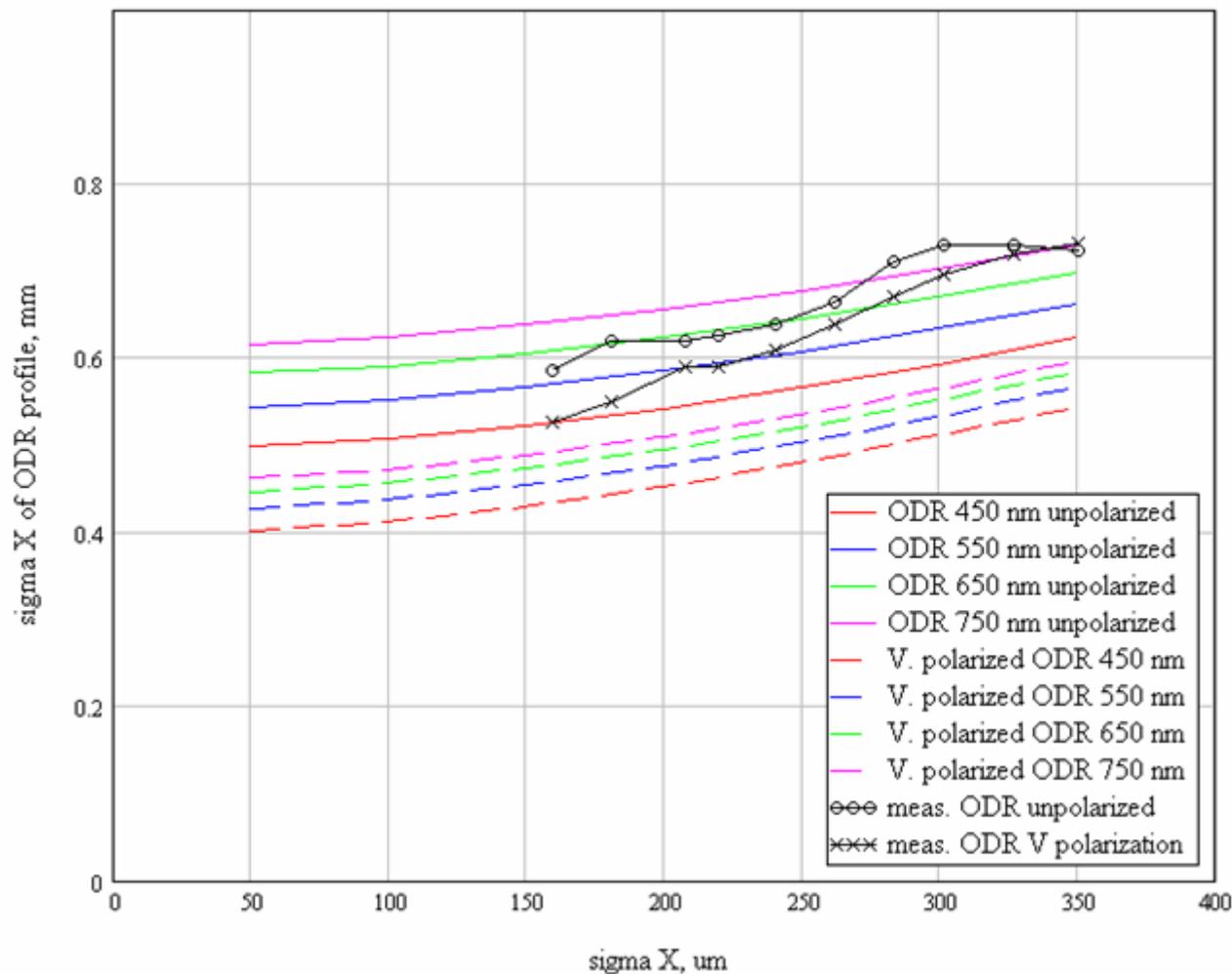
# OTR vs. wire scanner



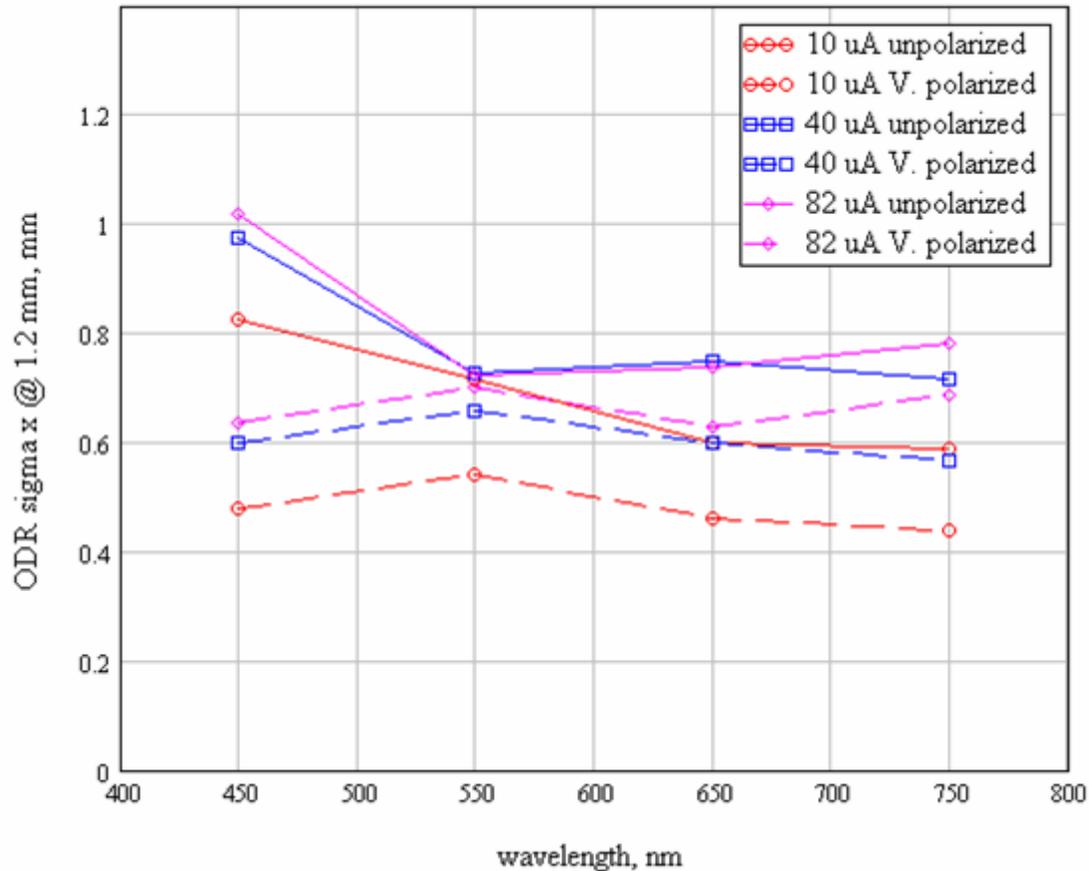
# ODR distribution vs. beam size



# The experiment vs. model

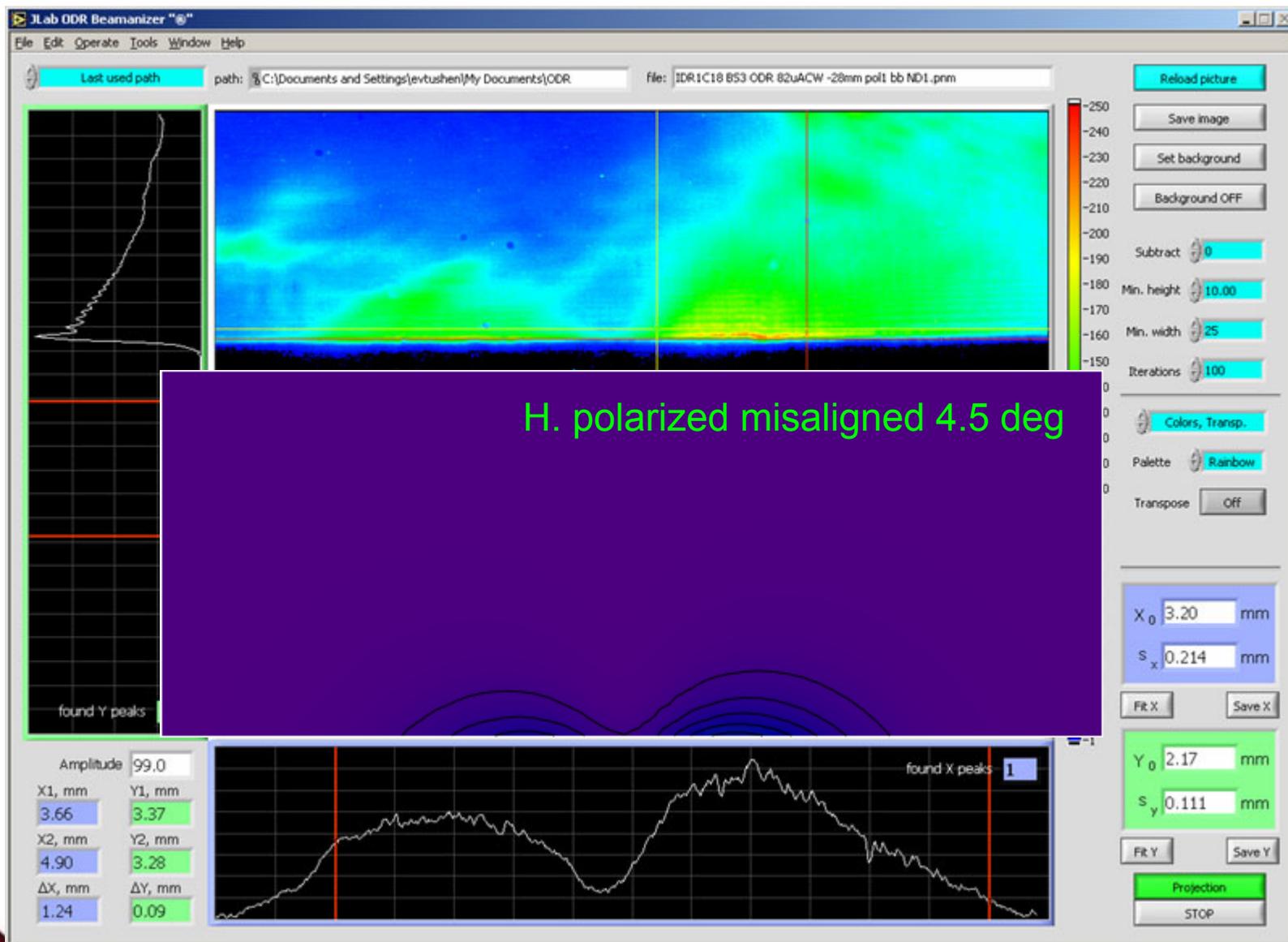


# ODR (unpolarized and V. polarized) vs. $\lambda$ and current

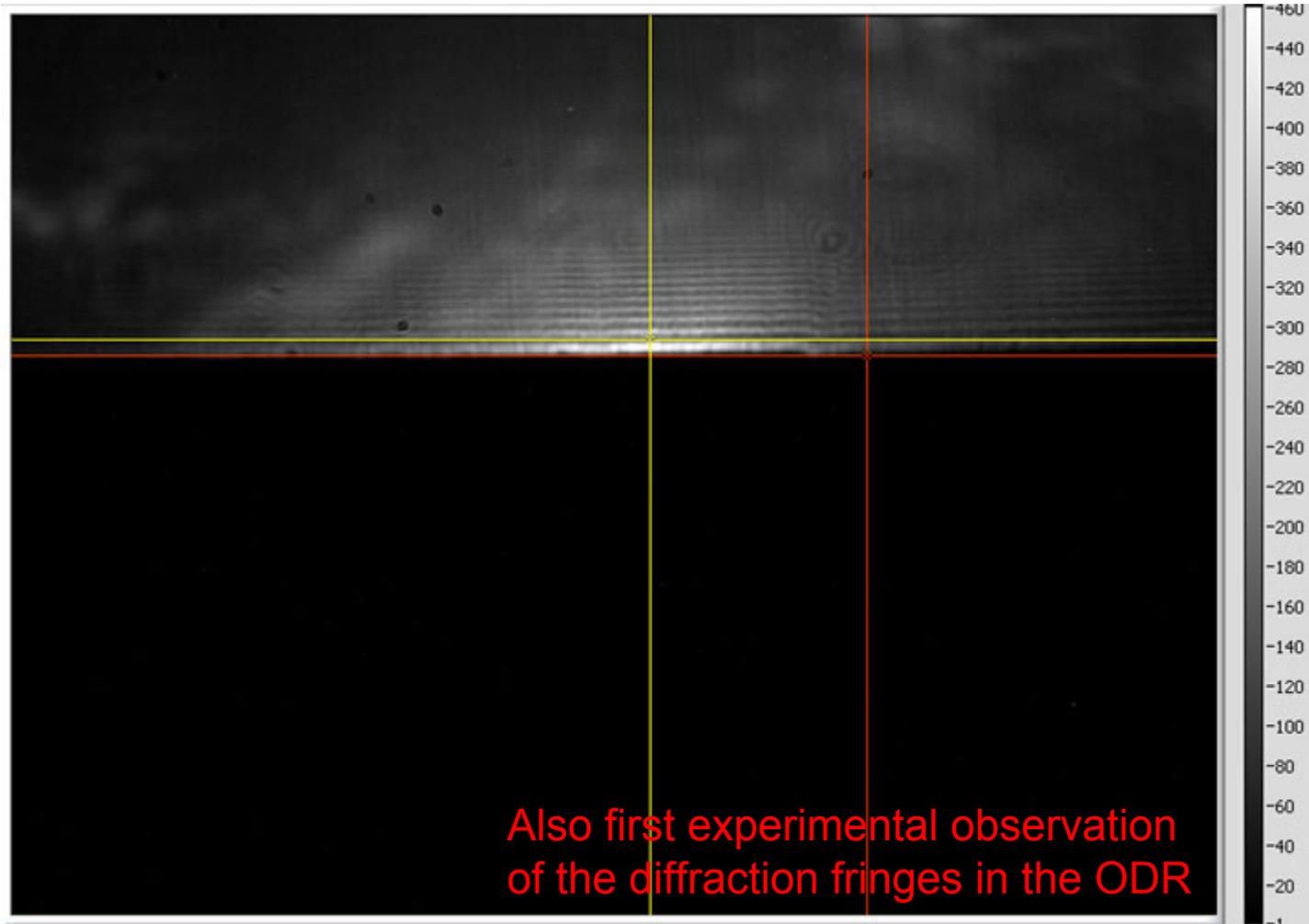


- the simple model predicts broader distribution for longer  $\lambda$  at any distance from the beam centroid; the data do not show it (?)
- the data suggest beam size change when going from 10  $\mu\text{A}$  to 40  $\mu\text{A}$ , but about the same beam size for 40  $\mu\text{A}$  and 82  $\mu\text{A}$

# H. polarized data ~60% asymmetry



# Diffraction fringes



Does look a lot like a classical diffraction on a straight edge.

But that requires transversally coherent wave front. Why is it coherent?

Because the source size ( $\lambda y$ ) is much bigger than transverse beam size.

# Conclusion

- ⊕ ODR measurements with CW beam up to 82  $\mu\text{A}$ ; no detectable beam loss;  $\sim 10\times\sigma_y$  away from the beam, very high signal level
- ⊕ demonstrated  $\sim$  linear ODR pattern (V. polarized) dependence on the  $\sigma_x$  in the range 150  $\mu\text{m}$  – 350  $\mu\text{m}$
- ⊕ for V. polarization data difference between the experiment and the model  $\sim 20\%$
- ⊕ strong and polarized background – make the data evaluation difficult (especially H. polarization)
- ⊕ very clearly observed diffraction fringes – transversal coherence of the field (source size ( $\lambda\gamma$ ) is much bigger than the beam  $\sigma_{x(y)}$ )
- ⊕ first observation of double lobe for the H. polarization data, the observed asymmetry might due to misaligned polarizer
- ⊕ have learned enough to refine the experimental setup
- ⊕ probably need more sophisticated modeling to explain details of experimental observation